

# Φ – 575 Διάλεξη 12

Φυσική διατάξεων δισδιάστατων ημιαγωγών

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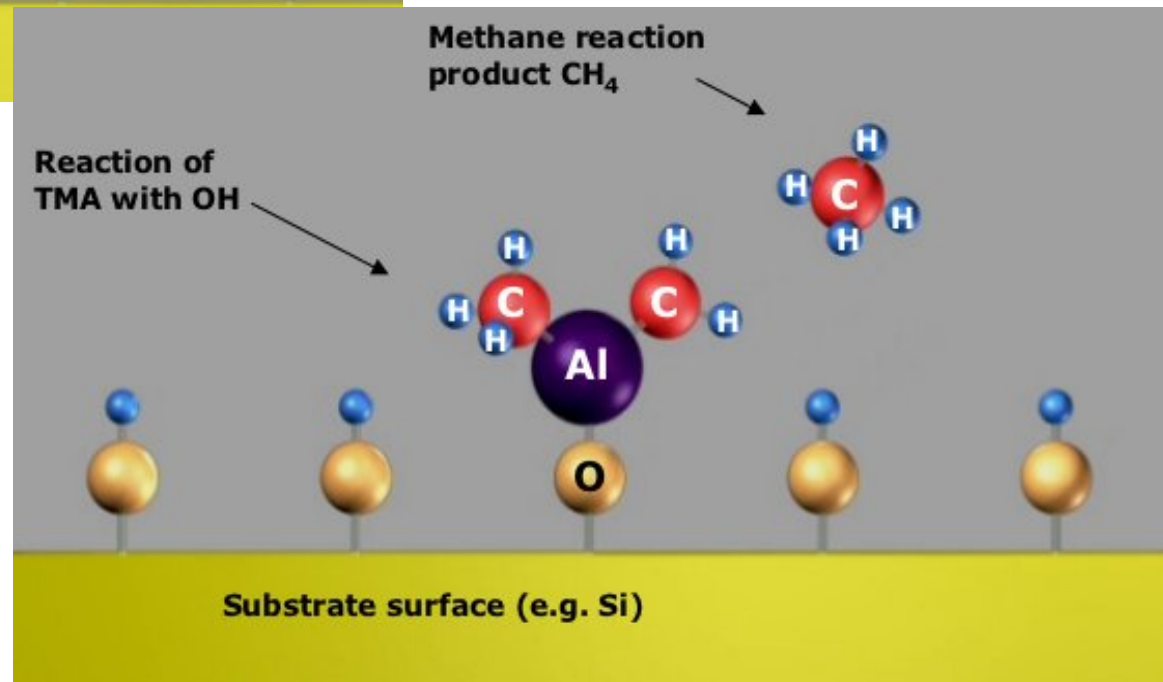
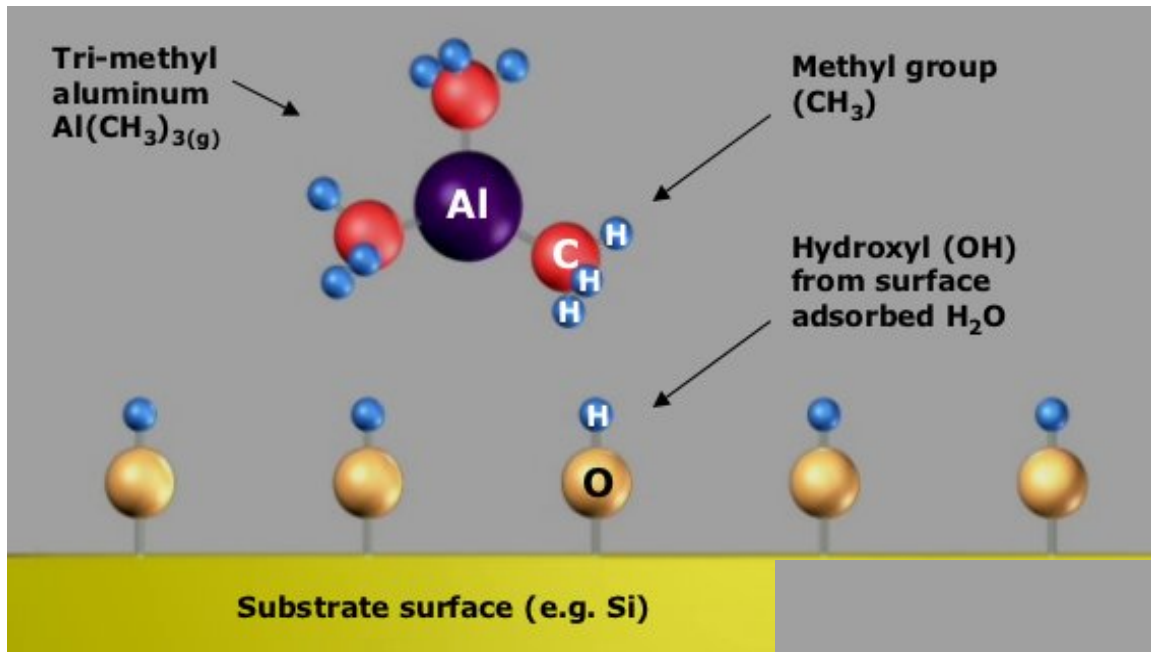
*Evaporation*

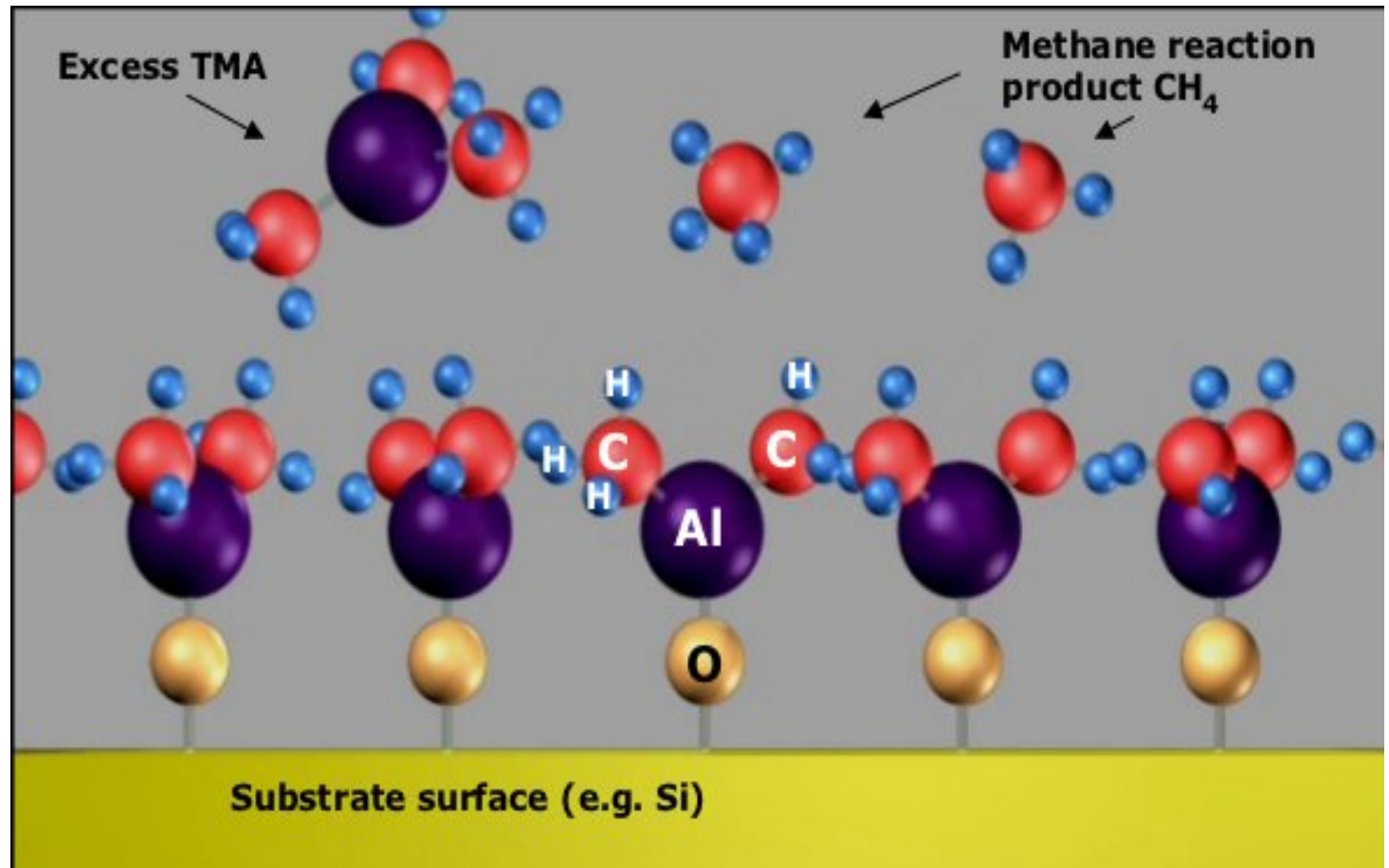
*Sputtering*

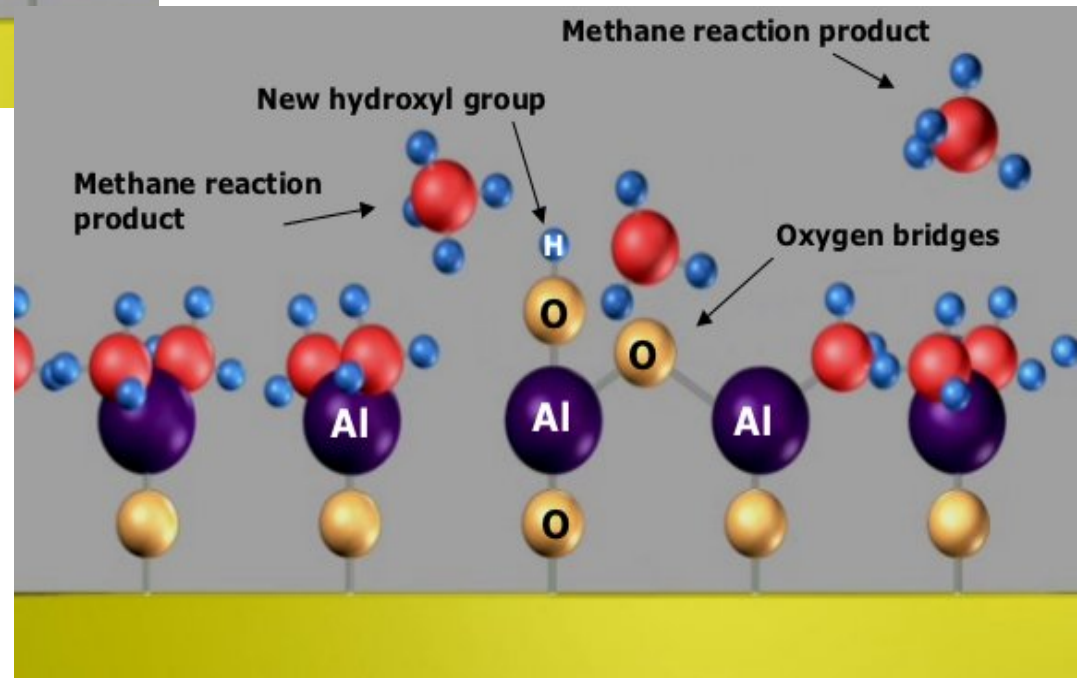
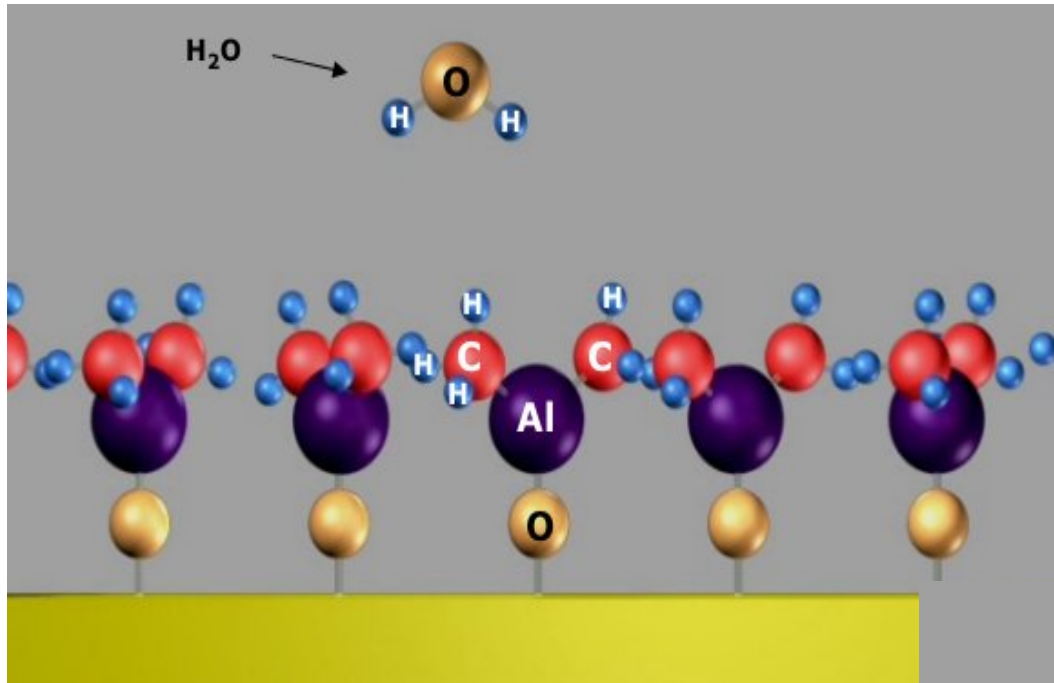
*(PE)CVD*

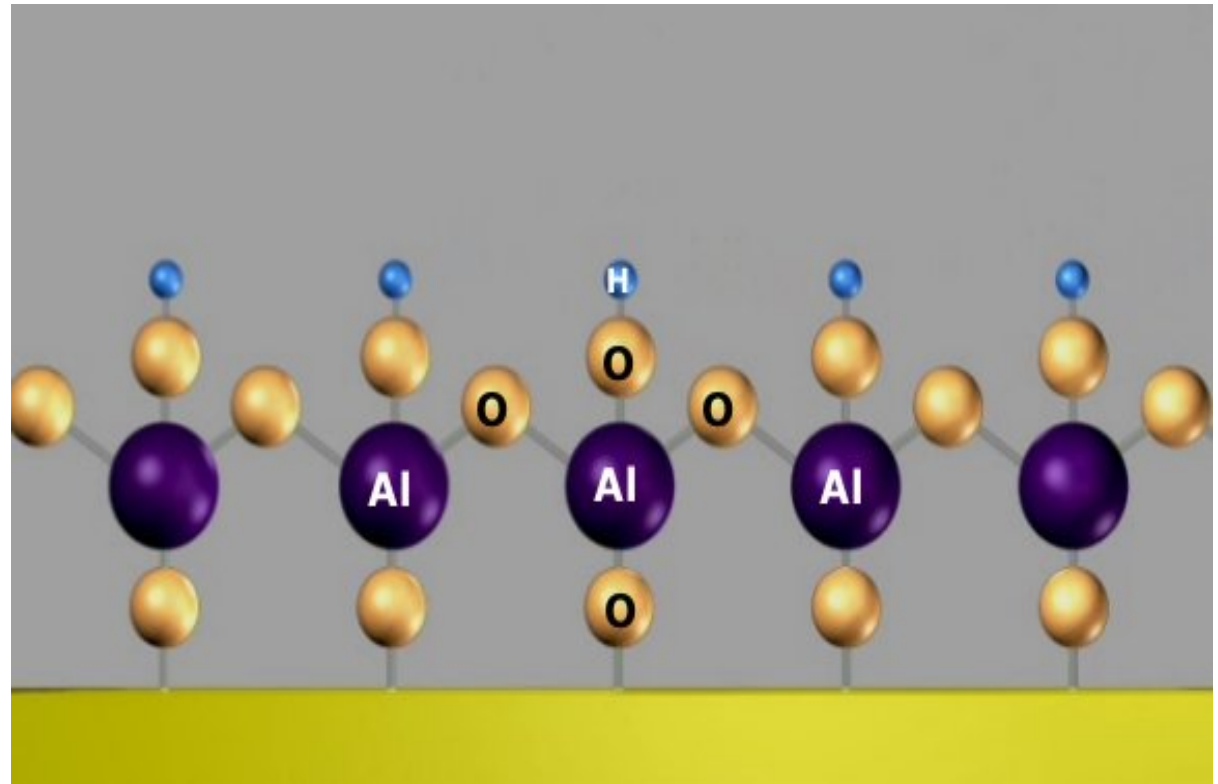
*2D dielectrics?*

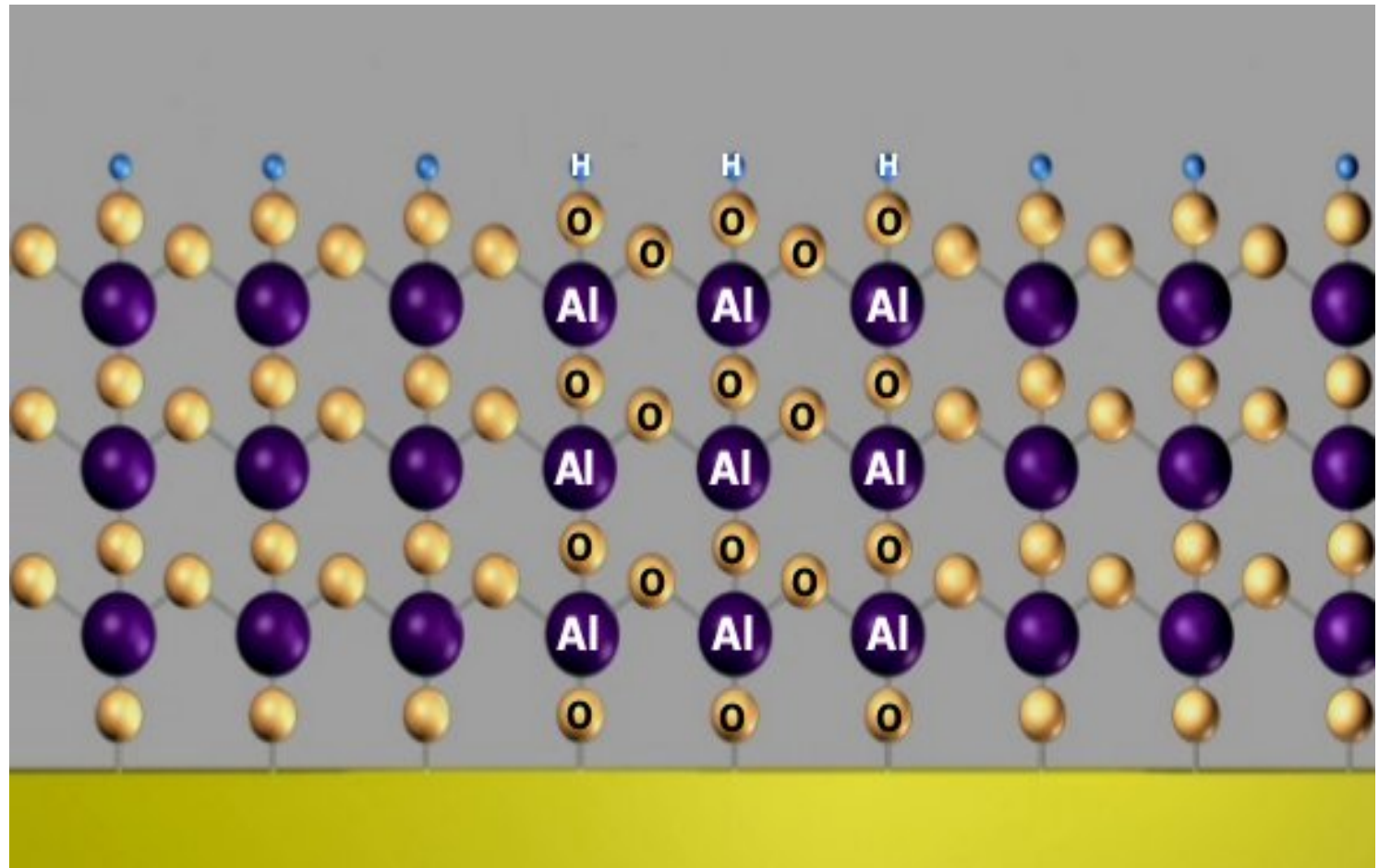
*Atomic layer deposition*













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- H. G. Kim and H.-B.-R. Lee, “Atomic Layer Deposition on 2D Materials,” *Chem. Mater.*, vol. 29, no. 9, pp. 3809–3826, May 2017, doi: 10.1021/acs.chemmater.6b05103.